

NEWS—MARCH 6, 2009

Jury finds for Rudolph Technologies in patent infringement action

MINNEAPOLIS, Minn.— Rudolph Technologies Inc. (NASDAQ: RTEC), says a Minneapolis jury has found in Rudolph's favor in its patent infringement suit against Israel's Camtek Ltd. The jury awarded Rudolph \$6.8 million in damages.



The technology used in this Rudolph NSX system was at the crux of the lawsuit.

The action concerns Rudolph's proprietary continuous scan wafer-inspection technology covered under its U.S. patent No. 6,826,298 for an "Automated Wafer Defect Inspection System and a Process of Performing such Inspection" which covers continuous inspection of wafers using strobing illumination.

In its award to Rudolph, the jury rejected Camtek's arguments that the '298 patent is invalid.

Rudolph is now seeking an injunction to prevent Camtek's Falcon inspection systems from being sold in the United States and elsewhere.

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